Nd:YVO4 is the most efficient laser host crystal for diode pumping among the current commercial laser crystals, especially, for low to middle power density. This is mainly for its absorption and emission features surpassing Nd:YAG. Pumped by laser diodes, Nd:YVO4 crystal has been incorporated with high NLO coefficient crystals (LBO, BBO, or KTP) to frequency-shift the output from the near infrared to green, blue, or even UV. This incorporation to construct all solid state lasers is an ideal laser tool that can cover the most widespread applications of lasers, including machining, material processing, spectroscopy, wafer inspection, light displays, medical diagnostics, laser printing, and data storage, etc.



It has been shown that Nd:YVO4 based diode pumped solid state lasers are rapidly occupying the markets traditionally dominated by water-cooled ion lasers and lamp-pumped lasers, especially when compact design and single-longitudinal-mode outputs are required.

Laser Properties of Nd:YVO4:

• One most attractive character of Nd:YVO4 is, compared with Nd:YAG, its 5 times larger absorption coefficient in a broader absorption bandwidth around the 808nm peak pump wavelength, which just matches the standard of high power laser diodes currently available. This means a smaller crystal that could be used for the laser, leading to a more compact laser system. For a given output power, this also means a lower power level at which the laser diode operates, thus extending the lifetime of the expensive laser diode. The broader absorption bandwidth of Nd:YVO4 which may reaches 2.4 to 6.3 times that of Nd:YAG. Besides more efficient pumping, it also means a broader range of selection of diode specifications. This will be helpful to laser system makers for wider tolerance for lower cost choice.

- Nd:YVO4 crystal has larger stimulated emission crosssections, both at 1064nm and 1342nm. When a-axis cut Nd:YVO4 crystal lasing at 1064m, it is about 4 times higher than that of Nd:YAG, while at 1340nm the stimulated cross-section is 18 times larger, which leads to a CW operation completely outperforming Nd:YAG at 1320nm. These make Nd:YVO4 laser be easy to maintain a strong single line emission at the two wavelengths.
- Another important character of Nd:YVO4 lasers is, because it is an uniaxial rather than a high symmetry of cubic as Nd:YAG, it only emits a linearly polarized laser, thus avoiding undesired birefringent effects on the frequency conversion. Although the lifetime of Nd:YVO4 is about 2.7 times shorter than that of Nd:YAG, its slope efficiency can be still quite high for a proper design of laser cavity, because of its high pump quantum efficiency.



- As high as about five times larger absorption efficient over a wide pumping bandwidth around 808 nm (therefore, the dependency on pumping wavelength is much lower and a strong tendency to the single mode output);
- As large as three times larger stimulated emission crosssection at the lasing wavelength of 1064nm;
- Lower lasing threshold and higher slope efficiency;
- As a uniaxial crystal with a large birefringence, the emission is only a linearly polarized.

Basic Properties:	
Atomic Density	1.26x1020 atoms/cm3 (Nd1.0%)
Crystal StructureCell Parameter	Zircon Tetragonal, space group D4h- I4/amda=b=7.1193Å,c=6.2892Å
Density	4.22g/cm3
Mohs Hardness	4-5 (Glass-like)
Thermal Expansion Coefficient (300K)	αa=4.43x10-6/Καc=11.37x10-6/Κ
Thermal Conductivity Coefficient (300K)	// C: 0.0523W/cm/K⊥C: 0.0510W/cm/K
Lasing wavelength	1064nm, 1342nm
Thermal optical coefficient (300K)	dno/dT=8.5×10- 6/Kdne/dT=2.9×10-6/K
Stimulated emission cross-section	25×10-19cm2 @ 1064nm
Fluorescent lifetime	90μs(1%)
Absorption coefficient	31.4cm-1 @810nm
Intrinsic loss	0.02cm-1 @1064nm
Gain bandwidth	0.96nm@1064nm
Polarized laser emission	polarization; parallel to optical axis (c-axis)
Diode pumped optical to optical efficiency	>60%

Technical Parameters:	
Chamfer	<λ/4 @ 633nm
Dimensional tolerances	(W±0.1mm)x(H±0.1mm)x(L+0.2/- 0.1mm) (L<2.5mm) (W±0.1mm)x(H±0.1mm)x(L+0.5/- 0.1mm) (L>2.5mm)
Clear aperture	Central 95%
Flatness	λ/8 @ 633 nm, λ/4 @ 633nm (tickness less than 2mm)
Surface quality	10/5 Scratch/Dig per MIL-O-1380A
Parallelism	better than 20 arc seconds
Perpendicularity	Perpendicularity
Chamfer	0.15x45deg
Coating	1064nm, R < 0.2%; HR Coating: 1064nm, R > 99.8%, 808nm, T > 95%

